High-Performance Planar Thin Film Thermochromic Window via Dynamic Optical Impedance Matching

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ABSTRACT: Window coatings with dynamic solar transmittance represent an excellent opportunity to reduce building heating and cooling loads, which account for >40% of energy consumed by the built environment. In particular, inorganic vanadium dioxide-based thermochromic coatings offer long lifetimes (>30 years) and can be passively integrated into a window system without additional electronics or power requirements. However, their limited solar modulation depth and wide phase-change hysteresis have traditionally restricted their ability to adapt to changing weather conditions. Here, we derive an optical performance limit for thin film vanadium dioxide coatings, which we find to be far beyond the current literature. Furthermore, we experimentally demonstrate a solution-processed multilayer thin film coating that uses temperature-dependent optical impedance matching to approach the optical performance limit. The thin film coating demonstrated has a record solar transmittance modulation of 21.8% while maintaining a high level of visible transparency (~50%) and minimal hysteresis (~10 °C). This work represents a step-change in thin film thermochromic window coatings and, as a result, establishes planar thin film vanadium dioxide as the most viable morphology for high-performance thermochromic windows.

KEYWORDS: vanadium dioxide, thermochromic, energy-efficient glazing, smart windows, optical coatings, thin films, dynamic solar control coatings

1. INTRODUCTION

Reducing energy consumption is vital to reducing CO₂ emissions and global warming. Heating and cooling loads account for >40% of energy consumed within the built environment, and window coatings with dynamic solar transmittance represent an excellent opportunity to reduce this load.6 In particular, inorganic vanadium dioxide-based thermochromic coatings offer long lifetimes (>30 years) and can be passively integrated into a window system without additional electronics or power requirements.7–10 The basic principle of a vanadium dioxide (VO₂) dynamic window coating is that in its low-temperature monoclinic VO₂(M) state, the coating is highly transparent to solar radiation, whereas in its high-temperature rutile VO₂(R) state, solar transmittance is reduced significantly,11 such that the dynamic window passively regulates solar heat gain in response to changing seasonal conditions.12 There are a number of fundamental material challenges associated with the performance of vanadium dioxide in dynamic window coatings, and progress in solving these challenges has most recently been reviewed by Faucheur et al.13 and Chang et al.9 Broadly, these challenges can be split into two categories: transition based, that is, the temperature-dependent hysteretic response of the coating, and the optical properties, that is, visible transparency and solar modulation ability. It is interesting to note that much of the early work investigating vanadium dioxide as a window coating material focused on using thin film deposition methods, such as sputtering14,15 or chemical vapor deposition, both of which can be implemented in large-scale manufacturing; however, a significant drawback of thin film vanadium dioxide as a dynamic window coating material is that changes in solar absorption and reflectance typically oppose each other,16–22 which dramatically reduces solar modulation ability. Nanoparticle-based coatings have been shown to improve the solar modulation because of reduced reflectivity and also because they exhibit a plasmon resonance in the high-temperature metallic state, which enhances attenuation around 1000 nm where solar intensities are relatively high.28–30 However, VO₂ coatings that utilize nanoscale features have other issues, such as significant phase-change hysteresis seen when particle domain sizes are small,27 which greatly reduces energy-saving performance as well as significant scattering and optical haze when larger nanoparticles are used.24 In this work, we rigorously derive and examine the optical constants of vanadium dioxide and find that the opposing changes in reflectance and absorption of thin film vanadium dioxide are a direct result of the opposing changes in the refractive index and
extinction coefficient that occur as a result of the thermochromic transition. In light of this, we present an alternative approach based on optical impedance matching in thin films, where the opposing changes in optical constants are no longer detrimental to solar modulation but rather taken advantage of in the optical design of the coating.

2. RESULTS

2.1. Thin Film Optical Constants. In Figure 1a,b the optical constants are shown for VO$_2$(M) and VO$_2$(R), respectively, whereas Figure 1c shows the shift in optical constants between low-temperature VO$_2$(M) and high-temperature VO$_2$(R). We observe that, as a result of the transition, the extinction coefficient increases across all solar wavelengths; conversely, for the refractive index, increases are seen only at longer wavelengths (>2000 nm), whereas decreases are seen below this wavelength (see Figure 1c). These opposing changes in the extinction coefficient and refractive index explain why absorption and reflectance oppose each other in thin films~superscript~11,21~superscript~26. The optical constants of VO$_2$(M) and VO$_2$(R) were obtained via ellipsometry with the fitted thickness of 96 nm, as confirmed by scanning electron microscopy (SEM, see Figure 1d). The measured ellipsometric parameters and the corresponding theoretical fit for multiple angles of incidence are shown in Figure S1. The optical constants were further verified by experimentally measuring the transmittance and reflectance of the thin film (see Figure 1e,f) and comparing with the transmittance and reflectance curves simulated using a transfer matrix method, with inputs of film thickness and optical constants taken from SEM and ellipsometry, respectively. The luminous transmittance $T_{lim}$ and solar transmittance modulation $\Delta T_{solar}$ of the fabricated thin film are 40.9 and 11.9%, respectively. We note that the fabricated thin film also exhibits the same issue observed in the literature, whereby changes in reflectance and absorption oppose one another, specifically between wavelengths of 600 and 1400 nm as can be seen from the reflectance spectra in Figure 1f. Specifically, the solar reflectance modulation $R_{solar}$ is $\sim$4.2517% (27.04 vs 22.78%), which accounts for a loss of >25% of the overall solar transmittance modulation.

2.2. Theoretical Limits. In our improved design, a thin film of vanadium dioxide is sandwiched between two transparent impedance matching layers (see Figure 2a), with the surrounding layers designed to optically impedance match between the low-temperature VO$_2$(M) state and the surrounding environment. In this case, when in the low-temperature VO$_2$(M) state, reflections are minimized across the entire solar spectrum and solar transmittance is maximized. When the thermochromic transition occurs, the impedance matching condition is broken and broad-band increases in reflectance are achieved (see Figure 2b); by matching optical impedance into and out of the thin film in its low-temperature VO$_2$(M) state, the thermochromic response is utilized beneficially for solar control, regardless of whether the change in refractive index is positive or negative, thereby maximizing solar modulation. Figure 2c shows this derived theoretical limit (ideal) for a thin film of vanadium dioxide (ranging from 0 to 250 nm thickness) in comparison with nonideal impedance matching conditions (instead assuming impedance matching from air to $n$ and also for the case of a 100 nm VO$_2$ film on a silica substrate (reference).
the perfect impedance matching limit could conceivably be achieved on industrial scales using a graded-index composite formed via cosputtering, where a high refractive index material would be sputtered simultaneously with a low-refractive-index material. The deposition rates of the two materials could then be varied to achieve a gradient index in-depth; however, in this work, we use a simpler multilayer structure with a few layers as a proof-of-concept.

3. MULTILAYER COATING

If we restrict our impedance matching condition to shorter wavelengths where solar irradiance is the highest (400−1000 nm), it can largely be achieved using thin film interference effects with only a few layers and, as we demonstrate here, provide great improvements to solar modulation. The materials used are chosen both for their optical properties (see Figure S2) and because of their well-established viability in the window coating industry. The top two silica (SiO2) and titania (TiO2(α)) layers have refractive indices (nD = 1.41 and 1.89, respectively) ranging between that of air and VO2(M) and so are able to effectively impedance match between air and VO2(M), provided that appropriate thicknesses are chosen. The bottom layer is a crystalline anatase titania (TiO2(A)) layer (see Figure S3 for crystallography and Raman analysis) with a refractive index (nD = 2.08) between that of the fused silica substrate (nD = 1.43) and VO2(M), with the layer thickness also chosen such that optical impedance is matched between VO2(M) and the silica substrate.

To determine the optimum thicknesses, a transfer matrix method was used to simulate the solar modulation ΔTsol and luminous transmittance Tsol of the structure. The vanadium dioxide layer thickness was held constant at 100 nm as this was expected to transmit >50% visible light; for greater visible transmittance, the thickness can be reduced at the cost of solar modulation as shown in Figure 2c. The surrounding impedance matching layers were varied in thickness between 20 and 300 nm. The maximum ΔTsol,max and Tsol,max from the parameter sweep were found to be 22.4 and 59.7%, respectively, however these respective optimum values occur for different thickness structures so a compromise is required. A figure of merit (FOM) is calculated to find structures that are able to compromise between the two performance metrics as defined by

\[
FOM = \left( \frac{\Delta T_{\text{sol}}}{\Delta T_{\text{sol,max}}} + \frac{T_{\text{sol}}}{T_{\text{sol,max}}} \right)^2
\]

In Figure 3a, the peak FOM found from a full sweep of titania and silica top layer thicknesses (20−300 nm) is given as a function of TiO2(A) layer thickness. A 60 nm thick TiO2(A) was chosen since thicker films (>150 nm) at the second maximum were found to show cracks after annealing. Figure 3b shows the FOM for a TiO2(A) layer thickness of 60 nm as a function of titania and silica top layer thicknesses (20−300 nm). The maximum FOM is found for 100 nm titania thickness and 110 nm silica thickness with 60 nm TiO2(A) thickness.

Figure 3. Selection of layer thicknesses: (a) selection of TiO2(A) layer thickness. Peak FOM found from full sweep of titania and silica top layer thicknesses (20−300 nm) as a function of TiO2(A) layer thickness. First maximum (60 nm) was chosen because thicker films (>150 nm) at the second maximum were found to show cracks after annealing. (b) Selection of top silica and titania layers. Peak FOM is found for 100 nm titania thickness and 110 nm silica thickness with TiO2(A) thickness of 60 nm.

Figure 4. Solution-processed multilayer with record performance: (a) Electron microscopy image of fabricated structure alongside the schematic design. (b) Clear view of London skyline (left) and the same view through the sample in the low-temperature state (right). (c) Spectral reflectance of the fabricated structure compared with simulation. (d) Spectral transmittance of the fabricated structure compared with simulation. (e) Relative transmittance as a function of temperature during heating and cooling. (f) First derivative of relative transmittance as a function of temperature.
In Figure 4a a schematic of our optimized design is shown alongside an electron microscopy image of the fabricated structure. Figure 4b shows the London skyline unobstructed (left) and also as seen through the sample in its low-temperature state (right). The view has a golden tint that is characteristic of the optical absorption band of VO2 (~500 nm). However, previous works have shown that the optical absorption band can be raised via doping to achieve a more neutral color. Importantly, there is no haze seen in the image, which is further evidenced via full optical characterization of transmittance haze across the visible range (see Figure S4). Figure 4c,d shows that the measured reflectance and transmittance spectra of the fabricated multilayer stack match well with simulation for both low-temperature and high-temperature states. The solar transmittance modulation of the measured spectra is 21.8%, and the visible transmittance is 48.9% (see Figure 5 for comparison with literature and our single VO2 thin film). Additionally, the hysteresis width and gradient width (see Figure 4f) of the fabricated structure are both narrow (12.9 and 10.1 °C, respectively), which is critical to the overall energy saving performance. The transition temperature of the coating is 69.3 °C, which is typical for undoped VO2 since titanium doping has been widely reported to raise the transition temperature of VO2, we can infer that there was no significant diffusion of titanium ions into the VO2 layer during the fabrication process.

4. CONCLUSIONS

In summary, we have shown theoretically that the optical performance limits of thermochromic vanadium dioxide window coatings are significantly higher than previously reported. We have subsequently used our theoretical observations to experimentally demonstrate a simple multilayer structure that has solar modulation far greater than any inorganic thin film thermochromic coating (>30% greater than current state-of-the-art) while maintaining a high degree of visible transparency (48.9%) and a narrow hysteresis (12.9 °C) and gradient width (10.1 °C). The additional materials used are common within the glass coating industry, and thin film fabrication methods are highly scalable. Therefore, once combined with metal ion doping to optimize the transition temperature, we anticipate that this design methodology will yield an optimal dynamic window coating highly viable for real-world application. Finally, the theoretical limit derived in this work shows that despite vanadium dioxide proposed as a dynamic window coating material over 30 years ago, the state-of-the-art is far from mature, with great room for innovation, and much more work still needs to be done.

5. METHODS AND MATERIALS

5.1. Synthesis of Spin Coating Solutions. The vanadium(IV) and silica solutions were synthesized following the methods described in our previous work.31 For the titaniasolution, a solution of titanium(IV) isopropoxide (TTIP) (Sigma-Aldrich, >97%), anhydrous isopropanol (IPA), and acetic acid (CH3COOH) (Sigma-Aldrich, >99.5%) was kept stirring for 0.5 h and used soon after. The volume ratios of the reactants were as follows: (TTIP/IPA/CH3COOH = 1:5:0.4).

5.2. Fabrication of Thin Films. The spin solutions were uniformly cast onto 2 in. fused silica substrates by spin coating at a range of spin speeds for 30 s (SCS G3 Spin Coater). All spin-cast films were aged in a box furnace at 100 °C for 10 min to remove any remaining solvent. The subsequent heat treatments varied for each desired material. Amorphous titanias (α) and silica SiO2 were obtained by heating in a box furnace at 150 °C for a further 1 h; anatase titania TiO2(A) was obtained by annealing in a tube furnace at 550 °C in air for 1 h, whereas monoclinic VO2 was obtained by annealing in a tube furnace at 550 °C for 1 h under vacuum (p < 20 mbar). The tube furnace was ramped up to and down from the set temperature at a ramp rate of 20 °C/min. Raman and X-ray diffraction (XRD) analysis showing the crystal phases within the sample are shown in Figure S4.

5.3. Material Characterization. XRD measurements were performed using a Bruker-AXS D8 (GADDS) diffractometer. SEM was carried out using a FEIInspect F microscope with a field emission gun. Raman spectroscopy was performed using an inVia confocal Raman microscope with laser power set to 1% to avoid sample heating. Optical constants of all materials used were measured using a Semilab SE-2000 spectroscopic ellipsometer (see Supporting Information). The optical constants for VO2(M) and VO2(R) were measured at room temperature and at 90 °C, respectively.

5.4. Performance Characterization. Thermochromic properties of the films were tested by measuring their transmittance and reflectance spectra. In order to remove any contribution of the substrate, a plain fused silica sample was measured as a background reference. The luminous transmittance Tlum and the solar modulation ΔTsol are defined by

\[ T_{\text{lum,sol}} = \frac{\int T_\lambda d\lambda}{\int \phi_\lambda d\lambda} \]

where the integrals taken between wavelengths (λ) of 300 and 2500 nm; \( \phi_\lambda(\lambda) \) is the photospectroscopic spectral sensitivity of human vision38 and \( \phi_{\text{lum}}(\lambda) \) is the AM 1.5 solar irradiance spectrum. The samples were heated in situ using an aluminum high-temperature cell controlled by a Eurotherm temperature controller and a T-type thermocouple. The hysteresis measurements were performed following the method described in our previous work.31 The scattering behavior of the films was measured in transmission using a Radiant Zemax Imaging Sphere for Scatter and Appearance Measurement, where samples were illuminated at a normal angle of incidence at 50 nm wavelength intervals between 400 and 700 nm wavelengths. The skyline image through the sample was taken using a Samsung Galaxy S7, with exposure and focus values set automatically without the presence of the sample and held constant for the subsequent measurement through the sample.

5.5. Simulations. Simulations of multilayer transmittance and reflectance were performed using a transfer matrix code written in MATLAB, with material properties for each material derived from ellipsometry.

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Characterization of visible transmittance haze and optical constants, material characterizations such as ellipsometry, XRD, and Raman spectroscopy, and additional electron microscopy images (PDF)

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**Notes**

The authors declare no competing financial interest.

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